

Daily Soothing Face Cream

Ingredient	INCI	% w/w
Phase A	'	1
A Leen 5	Pentylene Glycol	2.000
Keltrol CG-SFTv	Xanthan Gum	0.280
Hyaluronsäure 1.0-2.0mD	Sodium Hyalunorate	0.100
Phase B		
Purified Water	Aqua	69.010
2-Pflanzen Komplex	Glycerin, Aqua, Melilotus Officinalis Extract, Carica Papaya Fruit Extract	0.280
Evicide levulinate B	Aqua, Sodium Levulinate, Sodium Benzoate	2.500
Phase C		
Tegin M Pellets	Glyceryl Stearate	2.800
Emulgade PL 68/50	Cetearyl Glucoside, Cetearyl Alcohol	3.000
Lanette 16	Cetyl Alcohol	2.000
Dermofeel viscolid MB	Hydrogenated Vegetable Oil	1.400
MOD MB	Octyldodecyl Myristate	6.000
Cetiol C5C	Coco-Caprylate/Caprate	4.000
Phyto-Squalane	Squalane	1.800
Phase D		
Phenoliva Active 10	Olea Europaea Fruit Extract, Aqua, Citric Acid	0.100
Organic Aloe Vera Gel	Aloe Barbadensis, Citric Acid, Sodium Benzoate, Potassium Sorbate	1.200
Antileukine 6	Caprylic/Capric Triglyceride, Laminaria Ochroleuca Extract	2.000
PhytoCellTec Solar Vitis	Isomalt, Aqua, Vitis Vinifera Fruit Cell Extract, Lecithin, Sodium Benzoate	0.400
Vitamin F Forte	Linoleic Acid, Linolenic Acid	0.500
Phase E		
Citric Acid 50%	Citric Acid, Aqua	0.110
Total		100.000

- 1. Mix Phase A until it is homogeneous.
- 2. Add Phase B and mix for 20 min, heat to 75 °C.
- 3. Mix Phase C and heat to 75 °C.
- 4. Add Phase AB to Phase C and homogenise.
- 5. Cool down to 25 °C, add Phase D and homogenise.
- 6. Add Phase E to attain a pH 5.3.

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